

Method and apparatus for **cleaning** reverse-osmosis membrane modules.

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AB The title method is characterized by using pressurized **gas** and **liq.** 2 phase flow for backwashing reverse-osmosis membrane modules. A pressurized gas is intermittently supplied to a pressurized liq. phase flow for backwashing reverse-osmosis membrane modules. The app. include a pressurized water supply means, and a gas supply means for supplying a compressed gas to the pressurized water supply means. The reverse-osmosis membrane modules are used for desalination of seawater, etc.